

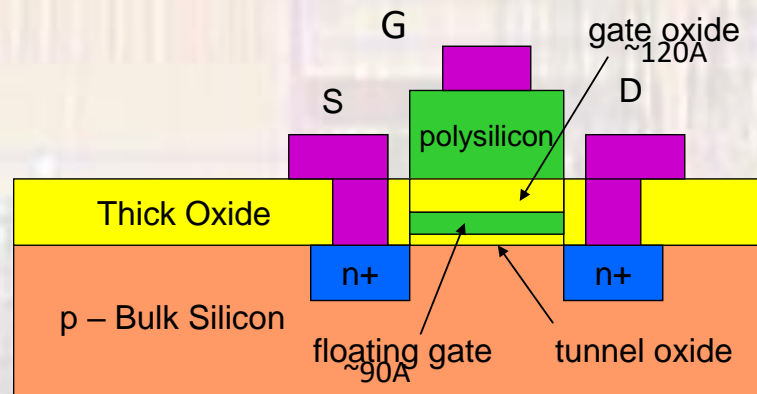
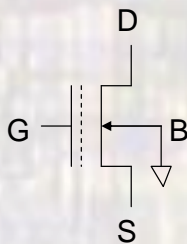
Memory - Flash

Last updated 3/26/25

Memory - Flash

- Flash Memory - basics
 - Memory cell (1 bit) is based on charge stored on a floating capacitor
 - The capacitor modifies the threshold voltage of a MOSFET
 - with negative charge stored – need higher gate voltage to turn on the MOSFET
 - Creates 2 possible threshold voltages

Different for NOR and NAND

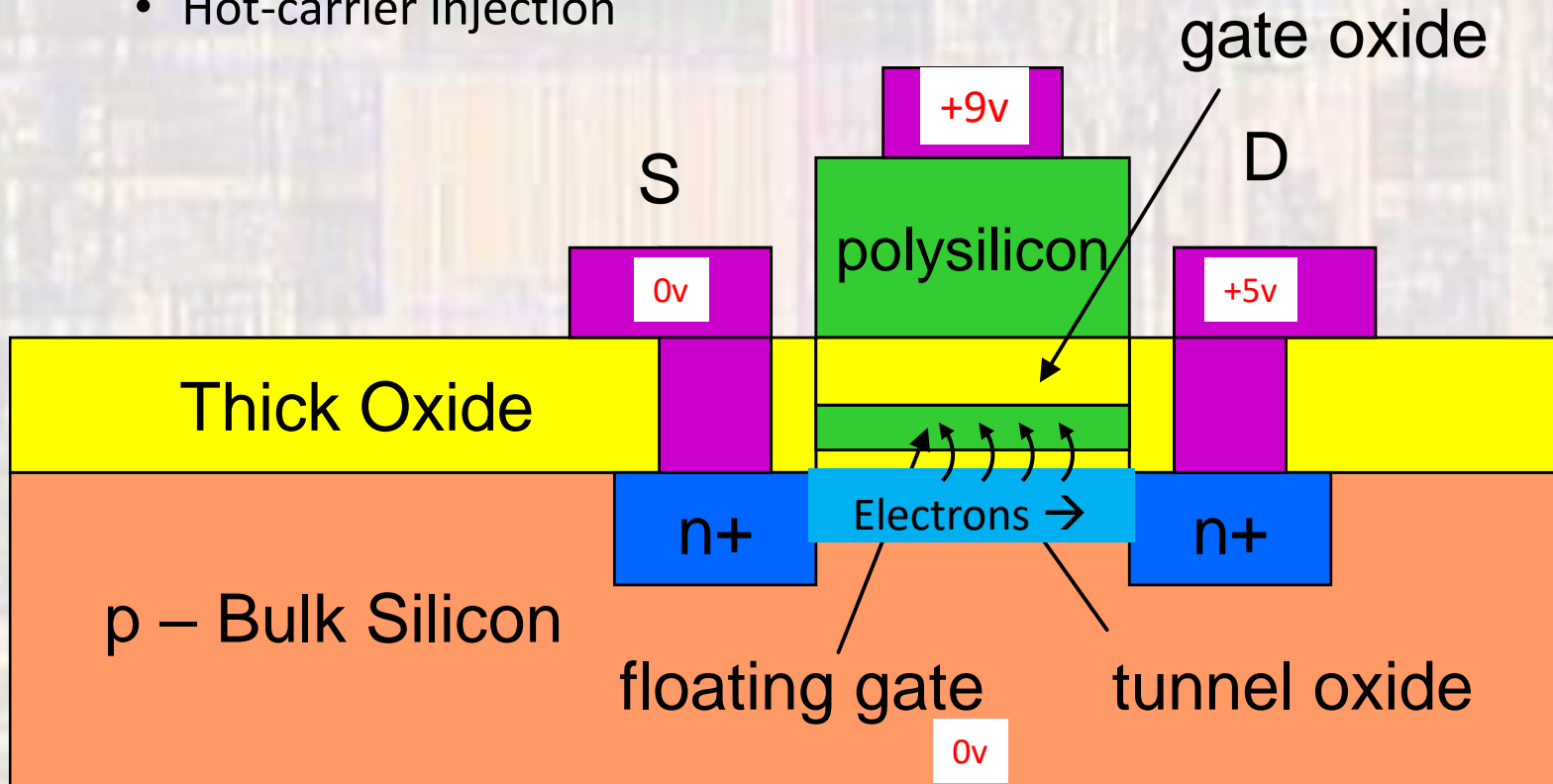


Memory - Flash

- Flash Memory

- Cell write

- High voltage process that allows electrons to be injected into the floating gate
- Hot-carrier injection

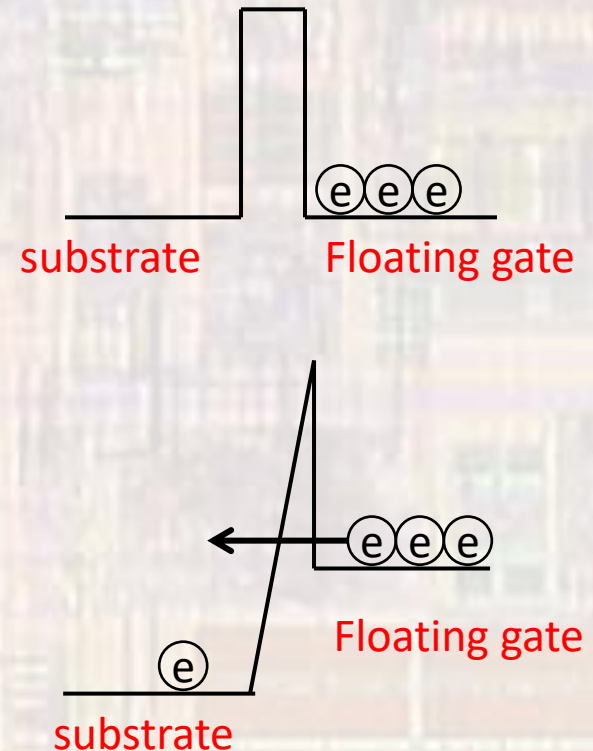
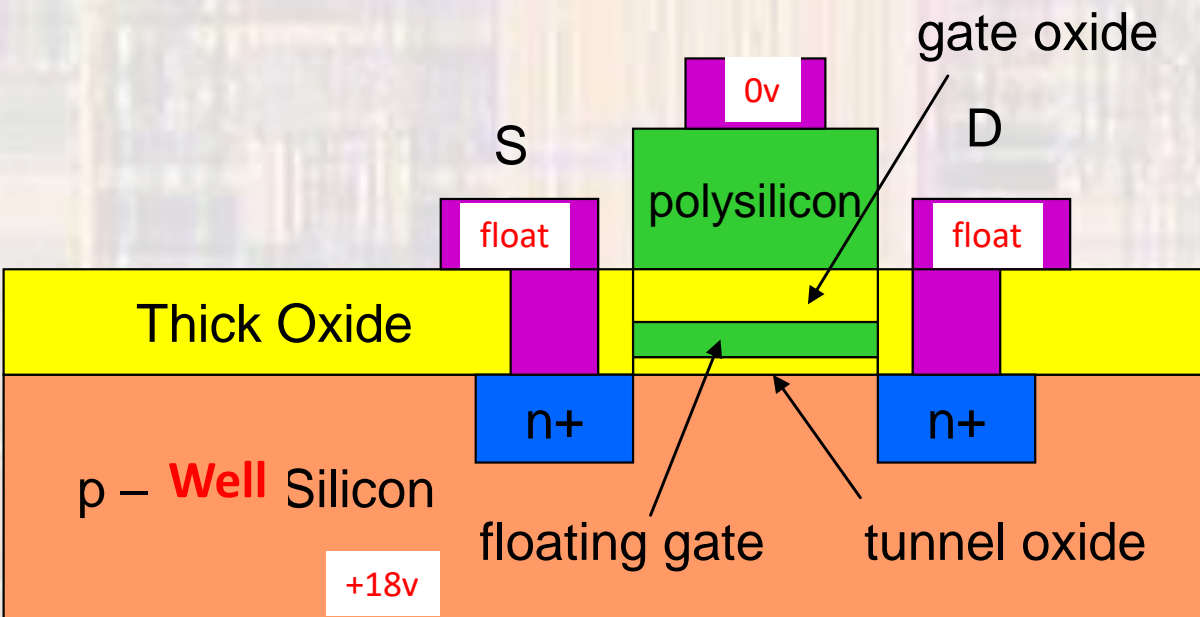


Memory - Flash

- Flash Memory

- Cell erase

- High voltage process that allows electrons to tunnel out of the floating gate
- Fowler-Nordheim Tunneling



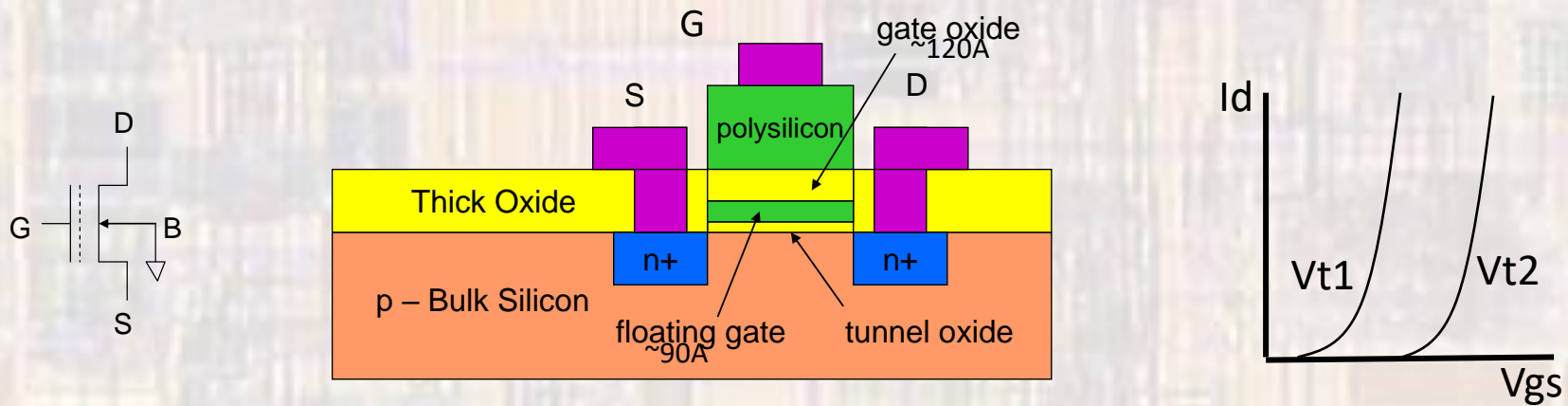
Memory - Flash

- Flash Memory

- Creates 2 possible threshold voltages

$V_{th \text{ High}}$ is required to turn on the MOSFET if charge is stored

$V_{th \text{ Low}}$ is required to turn on the MOSFET if no charge is stored

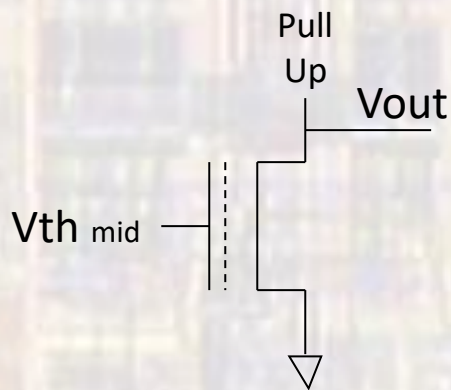


Memory - Flash

- Flash Memory

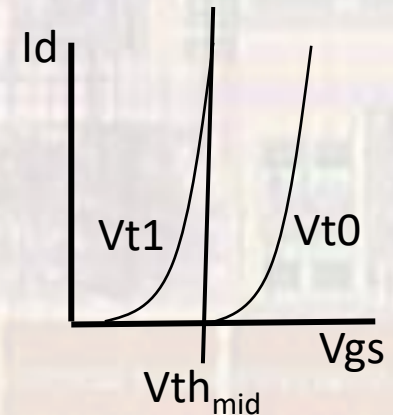
- Cell read

- Place a voltage on the gate midway between $V_{th\ High}$ and $V_{th\ Low}$
- Use the circuit to determine if the MOSFET is on or off
- Erased state – no charge stored = “1”
- Programmed state – charge stored = “0”



If charge stored on capacitor (programmed)
 $V_{th\ mid} < (V_{th} = V_{th\ High}) \rightarrow V_{out} = \text{high} \rightarrow \text{"0"}$

If no charge stored on capacitor (erased)
 $V_{th\ mid} > (V_{th} = V_{th\ Low}) \rightarrow V_{out} = \text{low} \rightarrow \text{"1"}$

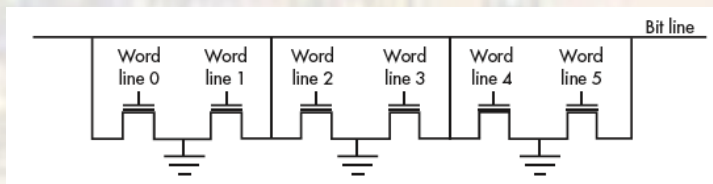


Memory - Flash

- Flash Memory

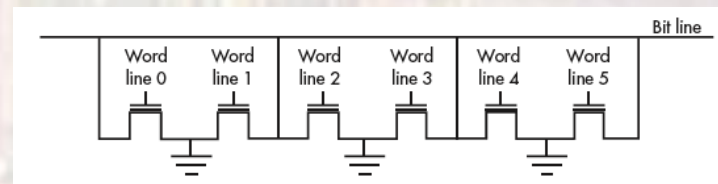
- NAND Flash

- Page Write
- Block Erase
- More dense
- Fast (required) sequential access
- Used as file storage memory (Flash Drives)



- NOR Flash

- Byte/word Write
- Block Erase
- Less dense
- Fast random access
- Used as program memory



Memory - Flash

- Flash Memory
 - Damage – wear out
 - The tunneling process damages the oxide layer
 - Some electrons get trapped in the oxide
 - Physical damage to the lattice
 - Limits the number of write/erase cycles
 - 10K – 1M cycles
 - Wear leveling
 - Remap the external addresses to new physical blocks on erases
 - Dynamic – do this as changes occur
 - Static – do this to little used blocks to make them available
 - Allows all blocks to approach their failure limit

Memory - Flash

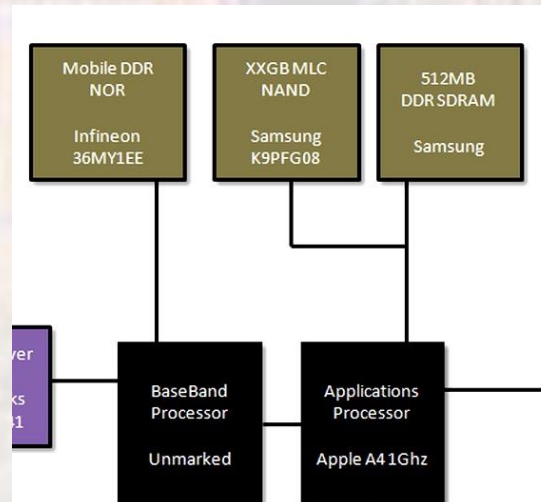
- Flash Memory
 - Multi-Level Cell
 - Instead of just having 2 threshold voltages – allow for 4 or 8
 - 4 → 2 bit MLC, 8 → 3bit MLC
 - All aspects of the design get harder (programming, read, wear leveling, speed) → ECC
 - Error Correction Coding – ECC
 - Additional bits are used to detect and correct bit level errors in a word

Memory - Flash

- Flash Memory

- Shadowing

- Store large amounts of program and data in Nand Flash
- At boot, copy a portion of the Nand memory into SRAM or SDRAM
- Use the SRAM/SDRAM as the processor program and data memory
- As additional program or data are needed – swap out a portion of the SRAM/SDRAM



Memory - Flash

- Flash memory
 - XIP – Execute in Place
 - Execute directly out of NOR flash
 - Nor Flash densities are growing rapidly
 - Nor Flash speeds are fast enough to support the memory hierarchy
 - Requires a caching system

Memory - Flash

- Other Technologies
 - Phase Change Memory – PRAM
 - Ferro-Magnetic Ram – FeRAM
 - Magneto-resistive Ram - MRAM